EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L8	289	(205/662.ccls. 204/229.4. ccls.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/27 15:34
S1	2	"5807165".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 10:21
S2	2	"20040060814".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 10:22
S3	3	"6706158".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 10:31
S4	55	intel.as. and ("204" "205"). clas.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 10:24
S5	60	((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz $3 planarizat$3)) and @ad<"20010901"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 10:37

S6	11	((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz$3 planarizat$3)) and @ad<"20010901" and ((voltage potential) with (control controll$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:09
S7	1971	((chemical chemically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz$3 planarizat$3)) and @ad<"20010901" and ((voltage potential) with (control controll$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:11
S8	0	((chemical chemically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz$3 planarizat$3)) and @ad<"20010901" and (((voltage potential) with (control controll$3)) same (temperature and (flow adj rate) and (speed near2 (rotation rotat$3))))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:14
S9	198	((chemical chemically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz$3 planarizat$3)) and @ad<"20010901" and (((voltage potential) with (control controll$3)) same (temperature))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:15
S10	22	((chemical chemically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz$3 planarizat$3)).clm. and @ad<"20010901" and (((voltage potential) with (control controll$3)) same (temperature))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:20

S11	6	((chemical chemically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz$3 planarizat$3)).clm. and @ad<"20010901" and ((((voltage potential) with (control controll$3)) same (flow adj rate))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:25
S12	68	((chemical chemically) adj (mechanical mechanically) adj (polish polish$3 planariz$3 planarizat$3)).clm. and @ad<"20010901" and ((((process process$3 polish polish$3) with (control controll$3)) same (flow adj rate))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:31
S13	62	((chemical chemically) adj (mechanical mechanically) adj (polish polish$3 planariz$3 planarizat$3)).clm. and @ad<"20010901" and ((((process process$3 polish polish$3) with (control controll$3)) same (speed near2 (rotation rotat$3)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:35
S14	10	((chemical chemically) adj (mechanical mechanically) adj (polish polish$3 planariz$3 planarizat$3)).clm. and @ad<"20010901" and ((((process process$3 polish polish$3) with (control controll$3)) same PID)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:35
S15	4	("6176992" | "6402925" | "6413403" | "6464855").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2009/01/26 17:14

| S16 | 4313 | (((((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz $3 planarizat$3))) electroprocess electroprocess$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process $3))) and @ad<"20010901" and ((voltage potential current) with (control controll$3 individual individually separate separate$3)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2009/01/26 17:37 |
| S17 | 2067 | (((((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz $3 planarizat$3))) electroprocess electroprocess$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process $3))) and @ad<"20010901" and ((voltage potential current) with (control controll$3 individual individually separate separate$3)) and (wafer workpiece substrate microelectronic) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2009/01/26 17:39 |

| S18 | 469 | ((((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz $3 planarizat$3))) ((electroprocess electroprocess$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process $3))) with (wafer workpiece substrate microelectronic))) and @ad<"20010901" and ((voltage potential current) with (control controll$3 individual individually separate separate$3)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2009/01/26 17:40 |
| S19 | 1210 | ((((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz $3 planarizat$3))) ((electroprocess electroprocess$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process $3))) with (wafer workpiece substrate microelectronic))) and ((((voltage potential current anode cathode electrode) with (individual individually separate separate$3 segment segment$3))) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2009/01/26 18:05 |

S20	877	(((((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz$3 planarizat$3))) ((electroprocess electroprocess$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process$3))) with (wafer workpiece substrate microelectronic))) and ((((voltage potential current anode cathode) with (individual individually separate separate$3 segment segment$3)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/26 18:05
S21	664	S20 not S18	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/26 18:06
S22	438	(((((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish$3 planarize planariz$3 planarizat$3))) ((electroprocess electroprocess$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process$3))) with (wafer workpiece substrate microelectronic))) and ((((voltage potential current anode cathode) with (individual individually separate separate$3 segment segment$3)))	US-PGPUB	OR	ON	2009/01/27 10:41

1/27/2009 3:57:28 PM
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